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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 6969

Keiichi MURAYAMA et al. : Docket No. 2003-1893A

Serial No. 10/748,158 : Group Art Unit 2814

Filed December 31, 2003 : Examiner Tuan N. Quach

HETERO-JUNCTION BIPOLAR TRANSISTOR
AND MANUFACTURING METHOD THEREOF

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEE FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975.

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents

P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Restriction Requirement of December 27, 2004, Applicants hereby elect **Invention I**, which is drawn to a bipolar transistor. Claims 1-13 are directed to the elected invention.

Having made the required election, a full examination on the merits of the elected invention is requested.

Respectfully submitted,

Keiichi MURAYAMA et al.

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